

IWM-10



The 10th anniversary of
International Workshop on
Microplasmas

Satellite workshop on
plasma metamaterials

Sponsors:
The Murata Science Foundation

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Katharina Stabelmann, North Carolina State Univ., USA
Osamu Sakai, Univ. of Shiga Prefecture, Japan
Kazuo Terashima, Univ. of Tokyo, Japan

Local organization committee

Osamu Sakai (Univ. Shiga Prefecture, chair)
Tsuyohito Ito (Univ. of Tokyo, co-chair)
Kazuo Terashima (Univ. of Tokyo)
Tatsuru Shirafuji (Osaka City Univ.)
Tomoyuki Murakami (Seikei Univ.)

Program of IWM10, 2019

Time	05/20 (Mon)	05/21 (Tue)	05/22 (Wed)	05/23 (Thu)	05/24 (Fri)	Time
9:00		Opening	K. Stapelmann		S-J. Park	9:00
9:30		V. S-v. Gathen	K. Tachibana	9:40~ O. Sakai	N. Milaniak	9:30
10:00		S. Remillard	K. Ishikawa	R. Michaud	H. Suzuki	10:00
10:30		S. Dzikowski Break	Break	S. Wu	Break	10:30
11:00		W. Choe	T. Goto	Break	W-H. Chiang	11:00
11:30		Y-K. Pu S-R. Sun	V. Kovacevic	D-S. Zhou J-S. Oh	P.P. Sun Closing	11:30
12:00		Lunch		Lunch		12:00
12:30	Registration desk open	Lunch		Lunch		12:30
13:00						13:00
13:30	Satellite Workshop Opening (Workshop)	C. Lazzaroni		H-X. Wang		13:30
14:00	J. Sokoloff	J. Hopwood	Excursion	M. Jinno		14:00
14:30	P.P. Sun	Y. Shimizu		T. Kaneko		14:30
15:00	D. Pai	M. Kanno		T. Murakami		15:00
15:30	Break	Y. Xu		Break		15:30
16:00	A. Smolyakov	Poster session		K. Sasaki		16:00
16:30	A. Semnani			Y. Nakagawa		16:30
17:00	T. Naito			Y. Baba		17:00
17:30	Closing (Workshop)	Poster session		K. Tomita		17:30
18:00	Welcome party	ISC meeting	Banquet			18:00
18:30						18:30
19:00						19:00
19:30						19:30
20:00	~20:00		~21:00			20:00

International Workshop on Microplasmas 2019

Monday, May 20th, 2019

13:40 – 14:00	O 1	<u>Opening (Workshop): Brief Review on Plasma Photonics Crystals, Plasma Metamaterials and Plasma Antennas: Opening of Satellite Workshop on Plasma Metamaterials</u>
		Osamu Sakai
		The University of Shiga Prefecture
	<i>Chaired by</i>	<i>Osamu Sakai, Univ. of Shiga Prefecture</i>
14:00 – 14:30	O 2	<u>Invited: Plasma-based microwave materials and devices</u>
		J. Sokoloff, ^{1*} T. Callegari, ¹ L. Liard, ¹ O. Pascal, ¹ R. Pascaud, ¹ and L. Simonchik ²
		1 Université de Toulouse
		2 Institute of Physics of NAS of Belarus
14:30 – 15:00	O 3	<u>Invited: THREE-DIMENSIONAL PHOTONIC CRYSTALS IN THE mm-WAVE REGION: RESONANCES, TUNABILITY AND SYMMETRIES</u>
		P. P. Sun, W. Chen, and J. G. Eden
		University of Illinois Urbana-Champaign
15:00 – 15:30	O 4	<u>Invited: Electron number density measurements from the frequency shift of a plasma defect state in a one-dimensional photonic crystal</u>
		David Z. Pai, ¹ Fabio Righetti, ² Benjamin C. Wang, ² David R. Biggs, ² and Mark A. Cappelli ²
		1 Université de Poitiers
		2 Stanford University
15:30 – 16:00		Break
16:00 – 16:30	O 5	<u>Invited: Plasmon resonances and reflection-less absorption in plasmas</u>
		Andrei Smolyakov ¹ and Natalia Sternberg ²
		1 University of Saskatchewan
		2 Clark University
16:30 – 17:00	O 6	<u>Invited: Plasma Metamaterial: A Potential Solution for Wideband Electrically-Small Antennas¹</u>
		Abbas Semnani, Sergey O. Macheret, and Dimitrios Peroulis
		Purdue University,
17:00 – 17:30	O 7	<u>Invited: Analytical study of plasma and antenna properties of linear plasma antennas</u>
		Teruki Naito ^{1, 2}
		1 Mitsubishi Electric Corporation
		2 The University of Shiga Prefecture
17:30 –		Closing (Workshop)
18:00 – 20:00		Welcome party (room 2)

Tuesday, May 21st, 2019

<i>Chaired by</i>	Kazuo Terashima, Univ. of Tokyo
9:00 – 9:20	Opening: Yi-Kang Pu, chair of international scientific committee
9:20 – 9:50 O 8	<u>Invited: Micro cavity plasma array devices: From first ignition to continuous operation</u> V. Schulz-von der Gathen, ¹ S. Dzikowski, ¹ M. Böke, ¹ R. Michaud, ² S. Iseni, ² and R. Dussard ² ¹ Ruhr-Universität Bochum ² Université d'Orléans
9:50 – 10:10 O 9	High Frequency Breakdown and Plasma Characteristics in a Microgap S.K. Remillard and W.G. Zywicki Hope College
10:10 – 10:30 O 10	Initial ignition behavior of a micro cavity plasma array (MCPA) Sebastian Dzikowski, Marc Böke, and Volker Schulz-von der Gathen Ruhr-University Bochum
10:30 – 10:50	Break
<i>Chaired by</i>	Remi Dussart, Univ. d'Orléans
10:50 – 11:20 O 11	<u>Invited: Electric wind generated by atmospheric pressure jet plasmas</u> Wonho Choe, ¹ Sanghoo Park, ¹ Uros Cvelbar, ² and Se Youn Moon ³ ¹ Korea Advanced Institute of Science and Technology ² Jožef Stefan Institute ³ Chonbuk National University
11:20 – 11:40 O 12	The evolution of a capacitively coupled argon discharge due to the sputtering of oxide layer on an aluminum electrode Jie Qiu and Yi-Kang Pu Tsinghua University
11:40 – 12:00 O 13	Investigation of chemical reaction processes for different arc-anode attachments in a high intensity argon arc Su-Rong Sun, Hai-Xing Wang, and Tao Zhu Beihang University
12:00 – 13:30	Lunch
<i>Chaired by</i>	Tatsuru Shirafuji, Osaka City Univ.
13:30 – 14:00 O 14	<u>Invited: Synthesis of boron nitride using a micro hollow cathode discharge deposition reactor</u> C. Lazzaroni, S. Kasri, H. Kabbara, G. Lombardi, V. Mille and A. Tallaire Université Paris 13
14:00 – 14:30 O 15	<u>Invited: Microplasma Formation in Metamaterials and Photonic Crystals</u> Jeffrey Hopwood and Hyunjun Kim Tufts University

14:30 – 14:50	O 16	Decoration of ZnO film with gold nanoparticles in open air by atmospheric-pressure micro-plasma jet and the photocatalytic properties of the decorated film
		Yoshiki Shimizu, Yoshie Ishikawa, Kazuto Hatakeyama, and Yukiya Hakuta
		National Institute of Advanced Industrial Science and Technology (AIST)
14:50 – 15:10	O 17	Electrophoretic deposition of TiN with field-emitting surface dielectric barrier discharge
		Moriyuki Kanno, Tsuyohito Ito, and Kazuo Terashima
		The University of Tokyo,
15:10 – 15:30	O 18	Deposition of Porous TiO₂ Films with a Pulsed RF Atmospheric Pressure Glow Discharge
		Yu Xu, ¹ Cheng-Ran Du, ¹ Sergey Kharapak, ² Ke Ding, ¹ Mierk Schwabe, ² Jian-Jun Shi, ¹ and Jing Zhang ¹
		¹ Donghua University
		² Deutsches Zentrum für Luft- und Raumfahrt (DLR)
15:30 – 16:00		Break
16:00 – 18:00		Poster session (room 2)
18:00 –		ISC meeting (room 1)

Poster session (Tuesday, May 21st, 16:00 – 18:00)

- P 1 **The determination of the electron energy distribution function for low pressure argon/krypton discharges**
Jie Qiu and Yi-Kang Pu
Tsinghua University
- P 2 **Study of ns-pulsed microplasma sources in N₂/Ar mixture**
S. Kasri,¹ L. William,¹ X. Aubert,¹ G. Lombardi,¹ A. Tallaire,¹ J. Achard,¹ and C. Lazzaroni,¹
G. Bauville,² M. Fleury,² K. Gazeli,² S. Pasquier,² and J. Santos Sousa²
1 Université Paris 13
2 Université Paris-Saclay
- P 3 **Influence of Applied Voltage on Electrostatic Elimination using Corona Discharge**
Katsuya Kubo,¹ Katsuyuki Takahashi,¹ Koichi Takaki,¹ Nozomi Takeuchi,^{2, 3} Shinichi Yamaguchi,^{1, 4} and Hidemi Nagata⁴
1 Iwate University
2 National Institute of Advanced Industrial Science and Technology (AIST)
3 Tokyo Institute of Technology
4 Shishido Electrostatic, Ltd.
- P 4 **Transient evolution of argon radio frequency atmospheric pressure discharge after the very first breakdown**
Z.F.Ding, M.Q.Du, and S.H.Fu
Dalian University of Technology
- P 5 **Atmospheric Radio Frequency Plasma Plume Enhanced by Pulsed discharge jet**
Jianjun Shi, Ying Guo, Qianhan Han, and Jing Zhang
Donghua University
- P 6 **Spatial Concentration Uniformity of Reactive Species Provided with a Scalable DBD Device**
Masaharu Shiratani,¹ Toshiyuki Kawasaki,² Ryoya Sato,¹ Kunihito Kamataki,¹ Naho Itagaki,¹ and Kazunori Koga¹
1 Kyushu University
2 Nishinippon Institute of Technology
- P 7 **Neutral gas temperature in silicon based DC MHCD operated in various gases near atmospheric pressure**
Sylvain Iseni,¹ Ronan Michaud,¹ Philippe Lefaucheux,¹ Goran Sretenovic,² Volker Schulz-von der Gathen,³ and Remi Dussart¹
1 UMR7344 CNRS/Univ. Orléans
2 Univ. of Belgrade
3 Ruhr-Univ. Bochum
- P 8 **Thermal Damage of a Glass Tube for Dielectric Barrier Plasma Jet Source**
Hiroto Matsuura, Yoshiki Matsui, Bounguang Ouanthavinsak, and Tran Trung Nguyen
Osaka Prefecture University

P 9	Plasma-assisted inkjet printing of molybdenum disulfide from ammonium tetrathiomolybdate aqueous solution Kaishu Nitta, Tomoya Kawano, Masanao Tsumaki, Kazuo Terashima, and Tsuyohito Ito The University of Tokyo
P 10	A Simple Ozone Treatment for Oxidizing Carbon Materials using Barrier Discharge Kazuto Hatakeyama, Yukiya Hakuta, Jun-ichi Sugiyama, and Yoshiki Shimizu National Institute of Advanced Industrial Science and Technology (AIST)
P 11	Plasma-assisted removal of oxygen traces from synthetic coke oven gases using a dielectric barrier discharge Kevin Ollegott, Philipp Wirth, Niklas Peters, Patrick Hermanns, Peter Awakowicz, and Martin Muhler Ruhr-University Bochum
P 12	Influence of a catalyst on the CO₂ conversion in a non-equilibrium atmospheric pressure helium plasma Theresa Urbanietz, Christoph Stewig, Steffen Schüttler, Marc Böke, Volker Schulz-von-der-Gathen, and Achim von Keudell Ruhr-University Bochum
P 13	Interaction between streamers and micro-pored catalyst pellets Sheng Zunrong and Tomohiro Nozaki Tokyo Institute of Technology
P 14	Durable, Self-healing and Super-hydrophobic Surfaces of Fabric Prepared by Plasma Coating Ying Guo, Liyun Xu, Jianjun Shi, and Jianyong Yu Donghua University
P 15	Plasma-assisted dielectric barrier discharge-driven catalysis for the combustion of volatile organic compounds Niklas Peters, Kevin Ollegott, Lars Schücke, Peter Awakowicz, and Martin Muhler Ruhr University Bochum
P 16	Characterization of a surface dielectric barrier discharge (SDBD) for purification of gas streams by conversion of volatile organic compounds (VOC) L. Schücke, B. Offerhaus, N. Peters, P. Wirth, K. Ollegott, M. Muhler and P. Awakowicz Ruhr University Bochum
P 17	Electron densities and temperatures of a ns-plasma in liquid: an experimental and theoretical study with OES and cavitation theory Katharina Grosse, Julian Held, Maike Kai, and Achim von Keudell Ruhr-University Bochum
P 18	3D Numerical Simulation of APPJ on the Flowing Water Surface Tatsuru Shirafuji, ^{1*} Jun-Seok Oh, ¹ and Masafumi Ito ² 1 Osaka City University 2 Meijo University

P 19	An 1.5 dimensional model of transient atmospheric pressure plasma jets
	M. Klich, ^{1*} Y. Liu, ² T. Mussenbrock, ² and R. P. Brinkmann ¹
	1 Ruhr University Bochum
	2 Brandenburg University of Technology
P 20	Reactive nitrogen/oxygen species in cold atmospheric nitrogen-oxygen plasmas
	Yuya Okamoto and Tomoyuki Murakami
	Seikei University
P 21	Modeling of the plasma sterilization on inflammation
	Yusuke Sakai and Tomoyuki Murakami
	Seikei University
P 22	Observation of Flattened Profile of Microwaves Propagation by Plasma-Metamaterials
	Chui Inami, ¹ Yuki Kabe, ¹ Akinori Iwai, ² Alexandre Bambina, ¹ Shigeyuki Miyagi, ¹ and Osamu Sakai ¹
	1 Univ. of Shiga Pref.
	2 Kyoto Univ.
P 23	DYNAMIC FILTERS THROUGH 3D MICROPLASMA METALLODIELECTRIC PHOTONIC CRYSTALS
	Peter P. Sun, ¹ Wenyuan Chen, ¹ Runyu Zhang, ¹ Z.H. Liang, ² Paul V. Braun, ¹ and J. Gary Eden ¹
	1 University of Illinois Urbana-Champaign
	2 Xi'an Jiaotong University

Wednesday, May 22nd, 2019

<i>Chaired by</i>	<i>Jeff Hopwood, Tufts Univ.</i>
9:00 – 9:30	O 19 <u>Invited: Unraveling plasma chemistry in liquids by using biochemical probes</u>
	Katharina Stapelmann, ¹ Brayden Myers, ¹ Duncan Trosan, ¹ Hager Mohamed, ² Leah Dobbosy, ² Keely Beyries-Powers, ² Fred Krebs, ² Vandana Miller, ² and Pietro Ranieri ¹
	1 North Carolina State University
	2 Drexel University
9:30 – 9:50	O 20 Dependency of Production Yield and Composition of Reactive Oxygen and Nitrogen Species on Discharge Schemes and Micro-structures
	Kunihide Tachibana and Toshihiro Nakamura
	Kyoto University
9:50 – 10:10	O 21 In-liquid plasma formation at low temperature of in situ binding SnO₂/Graphene
	Kenji Ishikawa, Rajit R. Borude, Hirotugu Sugiura, Takayoshi Tsutsumi, Hiroki Kondo, Nobuyuki Ikarashi, and Masaru Hori
	Nagoya University
10:10 – 10:40	Break
<i>Chaired by</i>	<i>Achim von Keudell, Ruhr-Univ. Bochum</i>
10:40 – 11:00	O 22 Decomposition of Various Organic Compounds by Microplasmas Generated within Oxygen Bubbles in Water
	Nozomi Takeuchi, ^{1, 2}
	1 Tokyo Institute of Technology
	2 National Institute of Advanced Industrial Science and Technology (AIST)
11:00 – 11:20	O 23 Plasma-surface-modification of inorganic materials in aqueous solution for high functional, flexible, and tough composite material
	Taku Goto, ^{1, 2} Tsuyohito Ito ¹ , Koichi Mayumi, ¹ Rina Maeda, ¹ Yoshiki Shimizu, ² Kohzo Ito, ¹ Yukiya Hakuta, ² and Kazuo Terashima ¹
	1 The University of Tokyo
	2 National Institute of Advanced Industrial Science and Technology (AIST)
11:20 – 11:50	O 24 <u>Invited: Spatio-temporally resolved electric field measurements in plasma jets</u>
	Vesna V. Kovačević, Goran B. Sretenović, Ivan B. Krstić, Bratislav M. Obradović, and Milorad M. Kuraica
	University of Belgrade
11:50 –	Excursion
18:00 – 21:00	Banquet

Thursday, May 23rd, 2019

<i>Chaired by</i>	<i>Tomoyuki Murakami, Seikei Univ.</i>	
9:40 – 10:00	O 25	Maze-Solving by Long-Path Microchannel Plasmas Toshifusa Karasaki and Osamu Sakai The University of Shiga Prefecture
10:00 – 10:20	O 26	Si-based Micro Hollow Cathode Discharges: from Fabrication to Application Ronan Michaud, Sylvain Iséni, Arnaud Stolz, Olivier Aubry, Philippe Lefaucheux, and Rémi Dussart UMR7344 CNRS/Univ. Orléans
10:20 – 10:40	O 27	The effects of the tube diameter on plasma properties of atmospheric-pressure microplasmas confined inside capillaries Shuqun Wu, Chang Liu, Xueyuan Liu, Lu Yang, and Chaohai Zhang Nanjing University of Aeronautics and Astronautics
10:40 – 11:10		Break
11:10 – 11:30	O 28	Effect of magnetic field configuration on needle-mesh corona discharge De-sheng Zhou, Jing-feng Tang, Xi-ming Zhu, and Chao-hai Zhang Harbin Institute of Technology
11:30 – 11:50	O 29	Microplasma Jet Contributes to Investigation of RONS Chemistry of Plasma-Activated Water Jun-Seok Oh, and Tatsuru Shirafuji Osaka City University
11:50 – 13:30		Lunch
<i>Chaired by</i>	<i>Katharina Stapelmann, North Carolina State Univ.</i>	
13:30 – 14:00	O 30	<u>Invited: Experimental Investigation of CO₂ Decomposition in a DC Micro-slit Sustained Glow Discharge Reactor</u> Hai-Xing Wang, Tao Ma, Su-Rong Sun, Qi Shi, and Shi-Ning Li Beihang University, Beijing
14:00 – 14:30	O 31	<u>Invited: Innovative Gene/Molecule Transfection Using Micro-plasma</u> Masafumi Jinno, ¹ Yoshihisa Ikeda, ¹ Yugo Kido, ² and Susumu Satoh ³ 1 Ehime University 2 Pearl kogyo Co. Ltd. 3 Y's corp.
14:30 – 14:50	O 32	Dominant Factors of In-Liquid Micro Plasma for Drug Introduction into Cells R. Honda, S. Sasaki, K. Takashima, M. Kanzaki, T. Sato, and T. Kaneko Tohoku University
14:50 – 15:10	O 33	Modeling the influence of cold atmospheric plasmas on intracellular metabolism Tomoyuki Murakami Seikei University

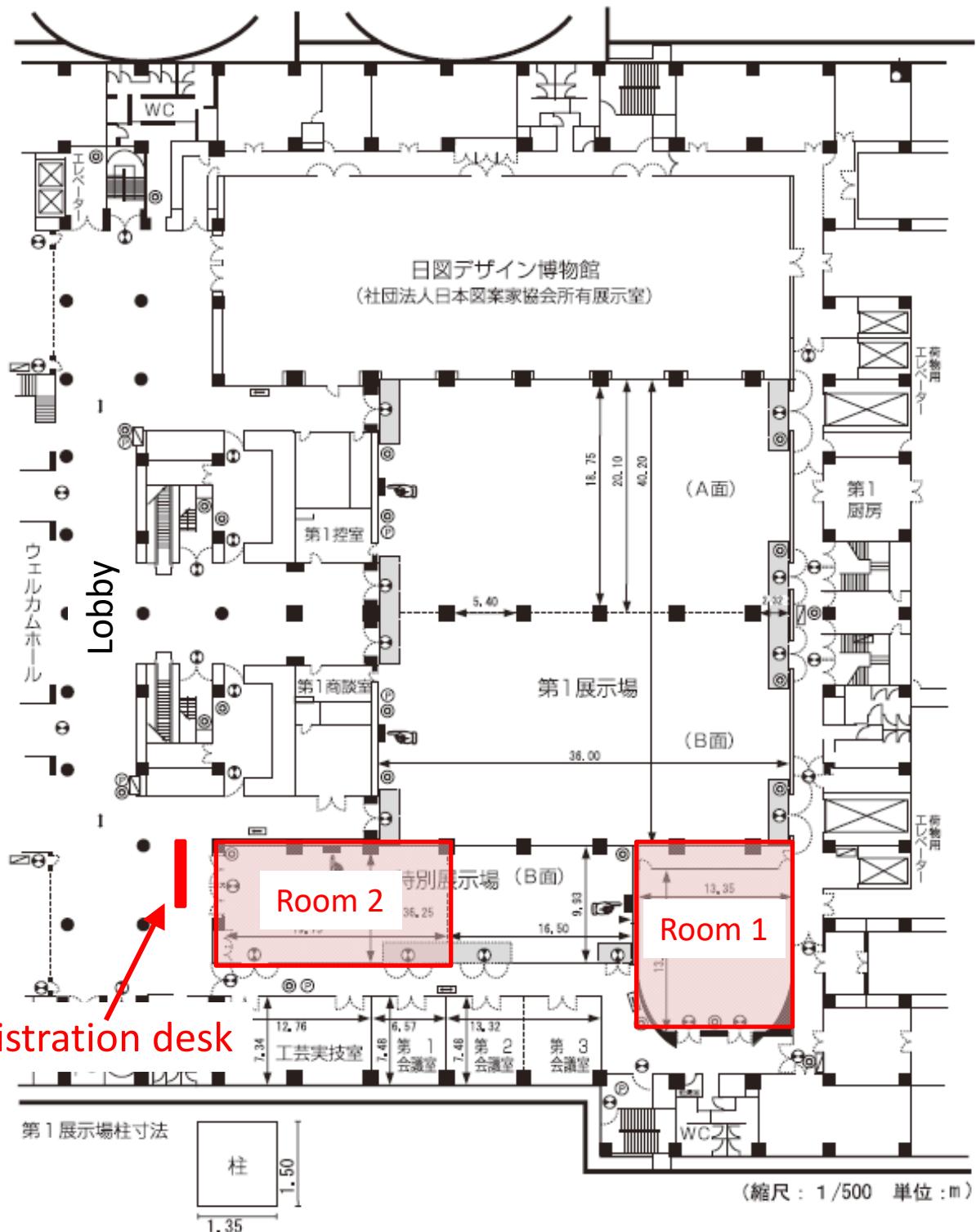
15:10 – 15:40	Break
<i>Chaired by</i>	<i>Yi-Kang Pu, Tsinghua Univ.</i>
15:40 – 16:00 O 34	Signal and noise in detection of OH radicals by evanescent-wave laser-induced fluorescence spectroscopy Koichi Sasaki and Yuto Hishida Hokkaido University
16:00 – 16:20 O 35	TALIF Spectroscopy of Atomic Nitrogen in Medium Pressure Pulsed Discharge Yusuke Nakagawa, Tatsuki Yoshii, Satoshi Uchida, and Fumiyoishi Tochikubo Tokyo Metropolitan University
16:20 – 16:40 O 36	Time-resolved microscopic measurement of slot excited atmospheric pressure microwave plasma Yoshiki Baba, Haruka Suzuki, and Hirotaka Toyoda Nagoya University
16:40 – 17:00 O 37	Measurements of Electron Density and Temperature of Pulsed Micro-Discharges in Atmospheric Pressure Using Laser Scattering and Emission Spectroscopy Methods Kentaro Tomita and Kiichiro Uchino Kyushu University
17:00 – 17:20 O 38	Time-resolved observation of femtosecond laser-induced plasmas in water Noritaka Sakakibara, ^{1, 2} Masahito Tanaka, ² Hiroyuki Toyokawa, ² Kazuo Terashima, ^{1, 2} Yukiya Hakuta, ² and Eisuke Miura ² 1 The University of Tokyo 2 National Institute of Advanced Industrial Science and Technology (AIST)

Friday, May 24th, 2019

	<i>Chaired by</i>	<i>Tsuyohito Ito, Univ. of Tokyo</i>
9:00 – 9:30	O 39	<u>Invited: Advancement of Microplasma Science and Technology in Nanoscale Processes and Environmental Science: A New Era of Microplasmas for the Technical and Social Impact</u>
		Sung-Jin Park
		University of Illinois Urbana-Champaign, Eden Park Illumination, Inc., EP Purification, Inc.
9:30 – 9:50	O 40	Innovative, plasma-based method for depositing multifunctional nanostructured thin films on the interior of a vascular graft
		Natalia Milaniak, ^{1,2} Gloria Bertrand, ¹ Françoise Massines, ² and Gaétan Laroche ¹
		1 Université Laval
		2 CNRS PROMES
9:50 – 10:10	O 41	Large-area surface treatment using microwave plasma excited in meter-length slot with sub-millimeter gap
		Haruka Suzuki, Hirotugu Koma, Manh Hung Chu, Hansin Bae, Yoshiki Baba, and Hirotaka Toyoda
		Nagoya University
10:10 – 10:40		Break
	<i>Chaired by</i>	<i>Jose L. Lopez, Seton Hall Univ.</i>
10:40 – 11:10	O 42	<u>Invited: Nanostructure Engineering using Microplasmas toward Functional Nanomaterials Synthesis and Applications</u>
		Wei-Hung Chiang
		National Taiwan University of Science and Technology
11:10 – 11:30	O 43	3D MICROPLASMA PHOTONIC CRYSTALS IN DIELECTRIC/METAL LATTICES
		Peter P. Sun, Wenyuan Chen, Runyu Zhang, Paul V. Braun, and J. Gary Eden
		University of Illinois Urbana-Champaign
11:30 –		Closing

Underground first floor (B1) of Miyako Messe

Main entrance side



Room 1: Oral presentation

Room 2: Poster presentation, Exhibition, Coffee

Wifi service will be available in both rooms.

Sorry that the map is in Japanese